



L. mono Selective Supplement II

FD213

A selective supplement recommended by ISO Committee for the isolation of *Listeria* species.

Composition

Per vial sufficient for 500 ml medium

*Ingredients	Concentration
Ceftazidime	10mg
Amphotericin B	5mg
Nalidixic acid, sodium salt	10mg

Directions:

Rehydrate the contents of 1 vial aseptically with 2 ml of 0.2 N Sodium hydroxide, further add 3 ml of sterile distilled water. Mix well and aseptically add it to 460 ml of sterile, molten, cooled (45-50°C) L. mono Differential Agar Base [M1540](#) / L. mono Differential HiVeg™ Agar Bas [MV1540](#) along with sterile contents of 1 vial of L. mono Enrichment Supplement I [FD214](#) and sterile rehydrated contents of 1 vial of L. mono Selective Supplement I [FD212](#) or add in 470 ml of sterile, molten, cooled (45-50°C) L. mono confirmatory Agar Base [M1552](#) / L. mono Confirmatory HiVeg™ Agar Base [MV1552](#) along with sterile contents of 1 vial of L. mono Enrichment Supplement II [FD227](#) and sterile rehydrated contents of 1 vial of L. mono selective Supplement I [FD212](#) . Mix well and pour into sterile petri plates.

Storage and Shelf Life

Store at 2-8°C. Use before the expiry date on the label.

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* Not For Medicinal Use

Disclaimer :

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